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| FORM PTO-1449 | U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE | | DOCKET NO. PU0246 | APPLICATION NO. To be assigned |
| INFORMATION DISCLOSURE STATEMENT BY APPLICANT | | | APPLICANT(S) Anders Larsson, et al. | 0/517293 |
| | | | FILING DATE To be assigned | GROUP ART UNIT To be assigned |

U.S. PATENT DOCUMENTS

| EXAMINER INITIAL | REF | DOCUMENT NUMBER | DATE | NAME | CLAS S | SUBCLASS | FILING DATE IF APPROPRIATE |
|------------------|-----|-----------------|-----------|---------------------|--------|----------|----------------------------|
| | A1 | 4,411,832 | 25-Oct-83 | Cuatrecasas, et al. | | | |
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U.S. PATENT APPLICATION PUBLICATIONS

| EXAMINER INITIAL | REF | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILING DATE IF APPROPRIATE |
|------------------|-----|-----------------|------|------|-------|----------|----------------------------|
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FOREIGN PATENT DOCUMENTS

| EXAMINER INITIAL | REF | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUBCLASS | TRANSLATION | |
|------------------|-----|-----------------|-----------|---------|-------|----------|-------------|----|
| | | | | | | | YES | NO |
| | B1 | WO 96/31549 | 10-Oct-96 | WIPO | | | | |
| | B2 | DE 196 21 741 | 04-Dec-97 | Germany | | | | |

OTHER DOCUMENTS

(Including Author, Title, Date, Pertinent pages, Etc.)

| EXAMINER INITIAL | REF | |
|------------------|-----|---|
| | C1 | CHERESTES, A., et al., "Dendrimeric ion exchange materials", <i>Polymer</i> , Volume 35, Number 15, 1994, Page 3343-3344. |
| | C2 | LING, F., et al., "Effect of Multivalency on the Performance of Enantioselective Separation Media for Chiral HPLC Prepared by Linking Multiple Selectors to a Porous Polymer Support via Aliphatic Dendrons", <i>J. Org. Chem.</i> , Volume 67, 2002, Page 1993-2002. |

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not conformance and not considered. Include copy of this form with next communication to applicant.